

## PATENT

## RANTH THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Chao-Hu Liang, Examiner: MAI, ANH D

5 Chih-Hung Chen,

Yu-Shan Tai

Po-Lun Cheng

Filing Date: 03/25/2002 Art Unit: 2814

Serial No.: 10/063,128 Docket No.: NAUP0385USA

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Title: METHOD OF FORMING A POLYSILCON LAYER

To: Commissioner for Patents

P.O. Box 1450

15 Alexandria, VA 22313-1450

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TECHNOLOGY CENTER 2800

Subject: Response to the Office Action dated 09/02/2003

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Dear Sir/Madam:

## INTRODUCTORY COMMENTS

In response to the Office Action identified above, the arguments are indicated in the following section. Consideration of all arguments is politely requested.